

# OPToelectronics devices introduction

①

OPTical absorption

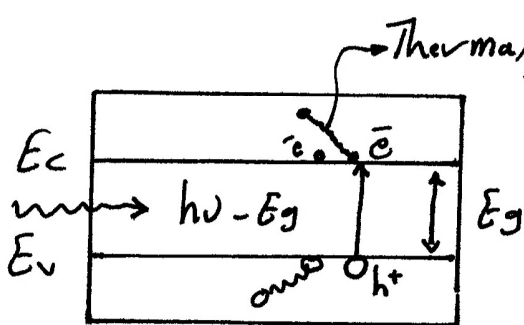
Semiconductor,  $E_g$ -band gap

$E < E_g$  - Transparent

$E > E_g$  - Opaque (absorb the light)

↳  $e^-$ -hole pairs (EHP)

↓      ↓  
CB    VB



$$h\nu > E_g \Rightarrow h\nu - E_g$$

access energy

↳ Lost by Thermalization

↳ Transferred to lattice.

$I$  = intensity of incident Radiation ( $W/A$ )

$$h\nu = \text{Energy of incident radiation } E = \frac{hc}{\lambda} \text{ (J)}$$

$$\Gamma_{ph} = \text{no of photons incident on the surface} = \frac{I}{h\nu}$$

$\alpha$  = absorption coefficient ( $cm^{-1}$ )

$I_0$  = incident intensity at the surface

$x$  = depth within material

$$I(x) = I_0 \exp(-\alpha x) \text{ Beer-Lambert law}$$

$$\frac{1}{\alpha} = \text{penetration depth } I = \frac{I_0}{e} = 0.37 I_0$$